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# Large-area growth of SnS<sub>2</sub> nanosheets by chemical vapor deposition for high-performance photodetectors

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Two-dimensional tin disulfide (SnS<sub>2</sub>) is very popular in electronic, optoelectronic, energy storage, and conversion applications. However, the uncontrollable large-area growth of SnS<sub>2</sub> nanosheets and unsatisfactory performance of the photodetectors based on SnS<sub>2</sub> have hindered its applications. Here, we propose a chemical vapor deposition (CVD) method using SnCl<sub>2</sub> as a precursor to grow SnS<sub>2</sub> nanosheets. We found that the as-grown SnS<sub>2</sub> nanosheets were high-quality crystal structures. Then, photodetectors based on the as-grown SnS<sub>2</sub> were fabricated and, exhibited a high responsivity (1400 A W<sup>-1</sup>), fast response rate (a response time of 7 ms and a recovery time of 6 ms), perfect external quantum efficiency (EQE) (2.6 × 10<sup>5</sup>%), and remarkable detectivity (*D*<sup>\*</sup>) (3.1 × 10<sup>13</sup> Jones). Our work provides a new CVD method to grow high-quality SnS<sub>2</sub> nanosheets.

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## Introduction

Tin disulfide (SnS<sub>2</sub>) is very popular in electronic,<sup>1–3</sup> optoelectronic,<sup>4–7</sup> and energy storage and conversion<sup>8–10</sup> applications because of its many fascinating properties, such as layered structure, wide-bandgap (≈2.2 eV), high absorption coefficient (10<sup>5</sup> to 10<sup>6</sup> cm<sup>-1</sup>), large carrier mobility (230 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>),<sup>11–13</sup> earth-abundance, and environmentally friendly nature. In particular, SnS<sub>2</sub>-based photodetectors showed an excellent responsivity, large on/off ratio, quick response, and fine stability,<sup>14</sup> so they will have a bright future in the practical or commercial electronic and optoelectronic areas.

As we know, only the controllable growth of SnS<sub>2</sub> nanosheets can allow its integrated electronic/optoelectronic applications. Many preparation methods of SnS<sub>2</sub> nanosheets have been studied including exfoliation,<sup>15</sup> the solvothermal method,<sup>16</sup> atomic layer deposition (ALD),<sup>17</sup> and chemical vapor deposition (CVD)<sup>18</sup> up to now. However, in the exfoliation of bulk materials it is difficult to control the size and thickness of the nanosheets, which limits its large-scale device fabrication. The solvothermal method needs a long reaction time and a complicated post-processing process. SnS<sub>2</sub> nanosheets prepared by ALD have the disadvantage of small size and different to transfer. CVD is expected to be the most promising method to grow various large-scale 2D materials. Peng *et al.*<sup>19</sup> first grew an array of SnS<sub>2</sub>

by CVD with a predefined location on the SiO<sub>2</sub>/Si substrates. But the critical nucleation site required a nanofabrication process, which needed a long time and might introduce impurities. Meng *et al.*<sup>6</sup> chose S and SnS<sub>2</sub> powders as the precursors to synthesize SnS<sub>2</sub> by CVD. Liu *et al.*<sup>20</sup> reported vertical SnS<sub>2</sub> synthesized on a fluorine-doped tin oxide (FTO) using CVD. However, the SnS<sub>2</sub> materials obtained by these results were not conducive to mass applications, because it was difficult to control the quality of products,<sup>6,19</sup> for example, the size, the uniformity, the thickness. Some photodetectors based on SnS<sub>2</sub> showed low responsivities or slow response rates.<sup>21</sup>

In this work, large-area SnS<sub>2</sub> nanosheets were grown through a CVD method by using SnCl<sub>2</sub> on SiO<sub>2</sub>/Si substrates as the precursors. The SnS<sub>2</sub> nanosheets-based photodetectors were fabricated to exhibit high responsivity (1400 A W<sup>-1</sup>), fast response rate (a response time of 7 ms and a recovery time of 6 ms), perfect external quantum efficiency (EQE) (2.6 × 10<sup>5</sup>%), and remarkable detectivity (*D*<sup>\*</sup>) (3.1 × 10<sup>13</sup> Jones). Our work may provide a new CVD method to grow SnS<sub>2</sub> nanosheets with high-quality.

## Materials and methods

### SnS<sub>2</sub> nanosheets synthesis and characterization

The SnS<sub>2</sub> nanosheets were synthesized using SnCl<sub>2</sub> on SiO<sub>2</sub>/Si substrates as the precursor and sulfurizing *via* a chemical vapor deposition (CVD) method. First, a stoichiometrical amount of tin chloride anhydrous (99.9%, Alfa) was melted thoroughly in ethanol to obtain a 0.2 M L<sup>-1</sup> SnCl<sub>2</sub> solution. Then the SnCl<sub>2</sub> solution was dispersed on a clean SiO<sub>2</sub>/Si substrate by spin-coating. The SiO<sub>2</sub>/Si substrates with SnCl<sub>2</sub> were sulfurized by CVD after evaporated the ethanol. For CVD growth, a quartz

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boat contained several SiO<sub>2</sub>/Si substrates with SnCl<sub>2</sub> was placed at the center of the furnace. Another quartz boat contained 0.1 g S powders (99.9%, Alfa) was placed on the upstream side of the furnace. The distance between the two quartz boats was about 10 cm. In the process of the SnS<sub>2</sub> growing, the furnace temperature was kept at 700 °C for 30 minutes, and then it was cooled to room temperature naturally. The flow rate of Ar gas was kept at 50 sccm all the time. The grown samples were characterized by an XRD (XRD-7000, Shimadzu), a field emission scanning electron microscope (JSM-7600F, JEOL, and Quanta650 FEG, FEI), an atomic force microscope (AFM, SPM9700, Shimadzu), and a transmission electron microscope (TEM, Tecnai G2 F30 S-TWIN, FEI). The Raman spectra were collected by an Argon ion laser Raman spectrometer (LabRAM HR800, Horiba Jobin Yvon) in the backscattering geometry with a 532 nm line. The Raman mapping was recorded by alpha300 R (WITec GmbH, Ulm, Germany) with a laser wavelength of 532 nm, and the scanning step interval was 300 nm.

### Photodetectors fabrication and measurement

For the photodetectors based on SnS<sub>2</sub> fabrication, the ethanol dispersion solution of the as-grown SnS<sub>2</sub> nanosheets was dropped on a SiO<sub>2</sub>/Si substrate first. Then the SnS<sub>2</sub> nanosheets-based photodetectors were fabricated using a standard electron beam lithography process (ELPHY Plus, Raith GmbH). The 10 nm Cr/50 nm Au electrodes were deposited by thermal evaporation (Nexdap, Angstrom Engineering). The photodetector was measured by a set of the photoelectric detection system, which contains a cryogenic probe station (CRX-6.5K, Lakeshore), a semiconductor characterization system (4200SCS, Keithley), a broadband laser-driven light source (LDLS, EQ-1500, Energetiq), and an oscilloscope (DSO-X 3052A, Keysight) with a 680 nm light pulse chopped at a frequency of 3 Hz.

## Results and discussion

Fig. 1a showed the schematic of grown the SnS<sub>2</sub> nanosheets *via* a CVD method. The crystal structures of the SnS<sub>2</sub> nanosheets were identified by XRD, and the results were shown in Fig. 1b. The obtained X-ray diffractometer pattern depicted that the as-grown nanosheets were pure hexagonal SnS<sub>2</sub> crystal phase (JCPDS card no. 23-0677).<sup>22</sup> Like MoS<sub>2</sub> crystals, each layer of SnS<sub>2</sub> consists of S–Sn–S, and the thickness is about 0.6 nm (in the inset of Fig. 1b). The top-view of the SEM image in Fig. 1c exposed the large amounts of SnS<sub>2</sub> nanosheets grew in the direction vertical to the SiO<sub>2</sub>/Si substrate, and the average size was about 15 μm. SiO<sub>2</sub>/Si substrates are 3D-bonded materials and have a large number of unsaturated dangling bonds on their surface. The migration barrier energies of SnS<sub>2</sub> adatoms on SiO<sub>2</sub>/Si substrates are expected to be larger the diffusion SnS<sub>2</sub> species tend to grow out-of-plane on SiO<sub>2</sub>/Si.<sup>23</sup>

We then verified the as-grown SnS<sub>2</sub> nanosheets using Raman spectroscopy. There are always two different polytypes (2H and 4H) in the two-dimension SnS<sub>2</sub> crystals.<sup>24</sup> In 4H-SnS<sub>2</sub> crystals, the most intense Raman peak at 313.5 cm<sup>−1</sup> is from a mixture of

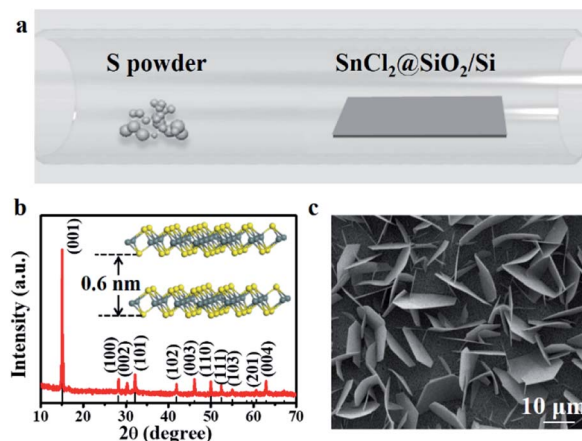


Fig. 1 (a) A schematic diagram of the CVD method. (b) XRD patterns of the as-grown nanosheets. Inset: crystal structure of the layered SnS<sub>2</sub> crystals. (c) A low-magnification SEM image of as-grown SnS<sub>2</sub> nanosheets.

A<sub>1</sub> and E optical modes, and the peaks at 200 and 214 cm<sup>−1</sup> are identified to be the E-mode. In 2H-SnS<sub>2</sub> crystals, the most intense peak at 315 cm<sup>−1</sup> is assigned to the A<sub>1g</sub> mode, and the peak at 205 cm<sup>−1</sup> is ascribed to the E<sub>g</sub> mode. And if the thickness decreased down to the nanoscale, the E<sub>g</sub> peak couldn't be detectable because of the reduction in the scattering centers for in-plane scattering in the ultrathin SnS<sub>2</sub> nanosheets.<sup>25</sup> Compare with the Raman spectra of the as-grown SnS<sub>2</sub> nanosheets, it's easy to find the SnS<sub>2</sub> nanosheets belong to 2H-SnS<sub>2</sub> (Fig. 2a). Raman mapping (Fig. 2b) demonstrated the uniformity of the as-grown SnS<sub>2</sub> nanosheet. The thickness of the SnS<sub>2</sub> nanosheet was about 9 nm from the result of the atomic force microscope (AFM), as shown in Fig. 2c. According to a monolayer thickness of ≈0.6 nm, the nanosheet was about 15 layers. SnS<sub>2</sub> is a semiconductor with an indirect bandgap of ~2.2 eV, the bandgap remains indirect in few-layer and monolayer flakes, which has been demonstrated by theoretical and experimental

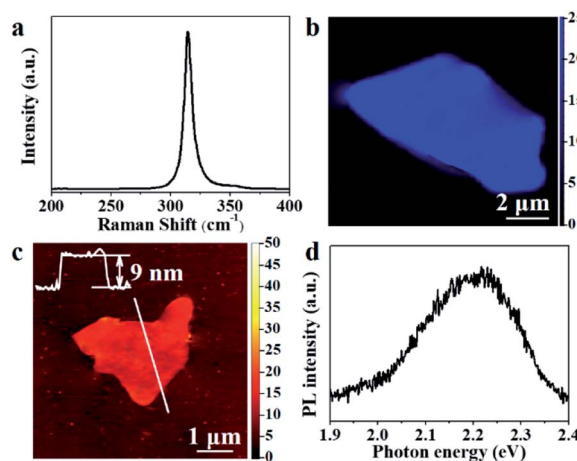


Fig. 2 (a) Raman spectrum of SnS<sub>2</sub> nanosheet. (b) Raman mapping data of SnS<sub>2</sub> nanosheet. (c) Typical AFM image of SnS<sub>2</sub> nanosheet. (d) PL spectra of SnS<sub>2</sub> nanosheet.

studies.<sup>24</sup> The PL spectra in Fig. 2d showed the bandgap of the as-grown SnS<sub>2</sub> nanosheet was  $\approx 2.2$  eV, which confirmed it had a high-quality crystalline structure.

To further evaluate the quality of as-grown SnS<sub>2</sub> nanosheets, we undertook a transmission electron microscope (TEM) to explore the lattice structure and the chemical composition information of the sample. Fig. 3a demonstrated a typical low-magnification TEM image of the SnS<sub>2</sub> nanosheet. The corresponding high-resolution TEM image in Fig. 3b showed the hexagonal lattice fringes, indicated the SnS<sub>2</sub> nanosheet had a perfect atomic structure with a lattice spacing of 0.316 nm, corresponding to the (01 $\bar{1}$ 0) and (10 $\bar{1}$ 0) planes. The selected area electron diffraction (SAED) and the sharp diffraction spots apparent in Fig. 3c also proved the high-quality crystalline hexagonal structure of the SnS<sub>2</sub>. Then, the elemental compositions of the SnS<sub>2</sub> nanosheet were acquired by the EDX mapping and the EDX spectrum. The EDX mapping in Fig. 3d and e, indicated the uniform distribution of Sn and S elements. EDX spectrum in Fig. 3f demonstrated the atomic ratio between S and Sn was approximately 2 : 1, which was consistent with the expected stoichiometry of SnS<sub>2</sub>. The TEM results further proved that the as-grown SnS<sub>2</sub> nanosheets were high-quality crystalline SnS<sub>2</sub>.

To investigate the optoelectronic properties of the SnS<sub>2</sub> nanosheet, photodetectors based on as-grown SnS<sub>2</sub> nanosheets have been fabricated. Fig. 4a illustrated the spectral response curve of SnS<sub>2</sub> nanosheets from 300 nm to 800 nm. The photoresponse decreased at the wavelength of  $\approx 560$  nm (bandgap of  $\approx 2.2$  eV), which was consistent with the result of PL in Fig. 2d. *I*-*V* characteristics under 680 nm light illumination of 2.1 mW cm<sup>-2</sup> and the dark, in air and vacuum of  $2.0 \times 10^{-2}$  Pa were showed in Fig. 4b. The symmetric behavior of the *I*-*V* curves indicated an ohmic contact between the 10 nm Cr/50 nm Au electrodes and the SnS<sub>2</sub> channel.<sup>26</sup> Regardless of under 680 nm wavelengths or the dark, the currents in vacuum were higher than those in air. It could be explained by an air adsorption/desorption mechanism. Because SnS<sub>2</sub> is an n-type semiconductor, its dominant carriers are the electrons. In the dark, the free electrons within the n-type SnS<sub>2</sub> channel will be trapped

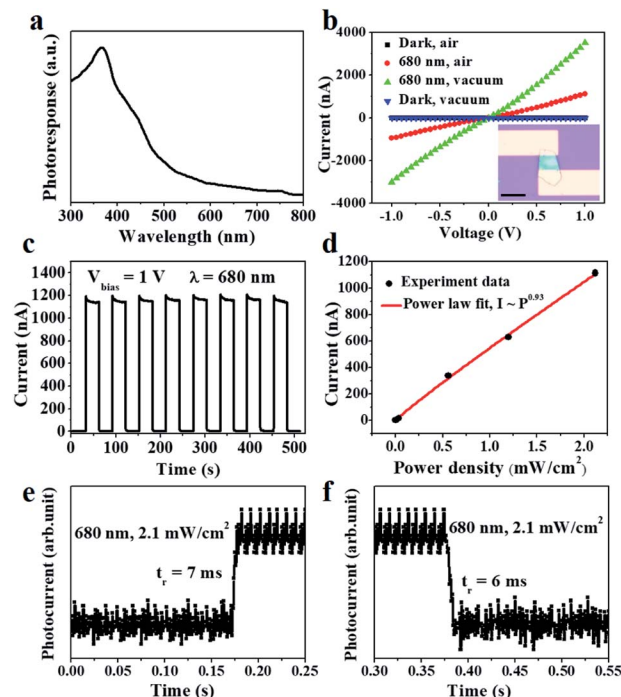


Fig. 4 (a) Spectral response curve of the SnS<sub>2</sub> nanosheet. (b) *I*-*V* characteristics under 680 nm wavelengths and the dark, in air and vacuum of  $2.0 \times 10^{-2}$  Pa. Inset: the optical image of the photodetector, the scale bar is 10  $\mu$ m. (c) Time-resolved photoresponse at a bias voltage of 1 V and an illumination power of 2.1 mW cm<sup>-2</sup> in air. (d) Photocurrent as a function of illumination intensity at  $V_{\text{bias}} = 1$  V in air. (e) and (f) Response and recovery curves of the photodetector in air.

by the air adsorbates on the surface of SnS<sub>2</sub> nanosheets. The loss in the area formed on the surface will lead to the decrease of carrier density in the channel.<sup>14,27</sup> However, if we turn on the incident light, the combination of the photogenerated holes (separated from electron-hole pairs) and the trapped electrons will release the air adsorbates on the SnS<sub>2</sub> surface. It is generally known that the air adsorbates such as oxygen could play an important role in the photoresponse process of other semiconductors especially for 2D semiconductors with a large specific surface area.<sup>28</sup> The surface trap states could achieve a longer lifetime of photogenerated carriers and thus guarantee a high  $R_{\lambda}$  and EQE.<sup>29</sup> As the results of the time-resolved photoresponse at a bias voltage of 1 V in air shown in Fig. 4c, the photodetector based on SnS<sub>2</sub> sustained a long-time stability response under switching on/off incident light illuminated on it periodically (Fig. 4c). The photo-responsivity ( $R_{\lambda}$ ) of the photodetector was calculated to be  $1.4 \times 10^6$  mA W<sup>-1</sup> through the equation:  $R_{\lambda} = I_{\text{ph}}/PS$ , where  $I_{\text{ph}} = I_{\text{light}} - I_{\text{dark}}$  is the photoexcited current,  $P$  is the light power intensity (2.1 mW cm<sup>-2</sup>), and  $S$  is the effective area under incident light (Fig. 4b inset). Such high responsivity may come from the efficient absorption and optimized device fabrication.<sup>14</sup> The external quantum efficiency (EQE) was also evaluated to be  $2.6 \times 10^5\%$ , based on the equation:  $\text{EQE} = hcR_{\lambda}/e\lambda$ , where  $h$  is the Planck's constant,  $c$  is the light velocity,  $e$  is the elementary electronic charge, and  $\lambda$  is

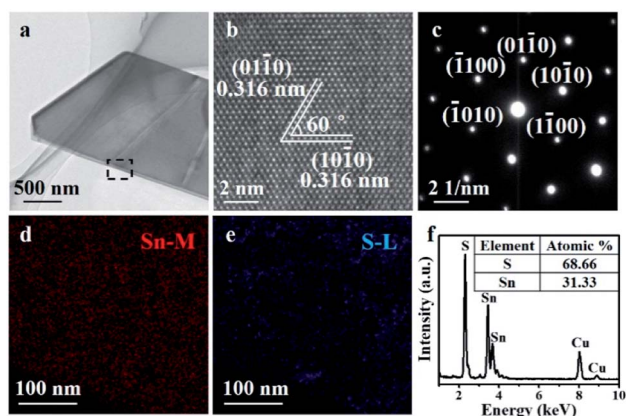


Fig. 3 (a) Low-magnification TEM image of the SnS<sub>2</sub> nanosheet. (b) High-resolution TEM image and (c) selected area electron diffraction (SAED) pattern image of the SnS<sub>2</sub> nanosheet. (d) and (e) Sn and S elemental mapping of the black rectangle region of the SnS<sub>2</sub> nanosheet in (a). (f) EDX spectrum of the SnS<sub>2</sub> nanosheet, inset: the ratio of Sn and S atoms.



Table 1 Comparison of the key parameters of our device to the reported 2D material based photodetectors<sup>a</sup>

Devices	Response range	Wavelength (nm)	$R_{\lambda}$ (mA W <sup>-1</sup> )	EQE (%)	$D^*$ (Jones)	Rise time (ms)	Ref.
SnS <sub>2</sub>	Vis	532	$1 \times 10^5$	—	—	44	24
SnS <sub>2</sub>	UV-NIR	830	$2.1 \times 10^{-4}$	—	—	460	21
SnS <sub>2</sub>	Vis	473	$1 \times 10^5$	$3.3 \times 10^4$	—	330	34
SnS <sub>2</sub>	Vis	457	8.8	2.4	$2 \times 10^9$	$5 \times 10^3$	19
SnS <sub>2</sub>	Vis	450	$2 \times 10^3$	—	—	42	6
SnS <sub>2</sub>	UV-Vis	405	$1.5 \times 10^3$	—	—	42	35
SnS <sub>2</sub>	UV-NIR	532	0.65	0.15	$1.13 \times 10^8$	360	27
SnS <sub>2</sub>	UV	350	$2.6 \times 10^5$	$9.3 \times 10^4$	$1.9 \times 10^{10}$	20	14
SnS <sub>2</sub>	Vis	400	$1.19 \times 10^3$	—	$2.4 \times 10^{11}$	<1	36
SnS <sub>2</sub>	Vis	490	$1.85 \times 10^3$	469	$4.9 \times 10^9$	43.4	23
SnS <sub>2</sub>	UV	390	—	150	—	—	37
SnS <sub>2</sub>	UV	365	$1.1 \times 10^6$	$3.2 \times 10^5$	$9.6 \times 10^{11}$	40	38
SnS <sub>2</sub>	Vis	405	$3.54 \times 10^5$	$1.1 \times 10^5$	$2 \times 10^{10}$	0.4	11
SnS <sub>2</sub>	Vis	532	$2.08 \times 10^3$	—	$6 \times 10^6$	$3.4 \times 10^3$	39
SnS <sub>2</sub>	UV	350	$8.6 \times 10^5$	$3.1 \times 10^5$	$1.1 \times 10^{10}$	700	40
BP	UV	365	$3.6 \times 10^8$	$1.6 \times 10^6$	$2.3 \times 10^{13}$	$1 \times 10^3$	41
SnS	UV-NIR	660	$9.2 \times 10^5$	$1.7 \times 10^5$	$1.09 \times 10^9$	0.12	42
PtS <sub>2</sub>	UV-NIR	830	$3 \times 10^2$	—	—	0.1	43
PtSe <sub>2</sub>	NIR	632	$4.5 \times 10^3$	—	$7 \times 10^8$	1.1	44
PdSe <sub>2</sub>	IR	1064	$7.1 \times 10^5$	—	$1.3 \times 10^9$	—	45
SnS <sub>2</sub>	Vis	680	$1.4 \times 10^6$	$2.6 \times 10^5$	$3.1 \times 10^{13}$	7	This work

<sup>a</sup>  $R_{\lambda}$  – photo-responsivity, EQE – external quantum efficiency,  $D^*$  – detectivity.

the excitation light wavelength. The specific detectivity ( $D^*$ ) is  $3.1 \times 10^{13}$  Jones according to the equation of  $D^* = R_{\lambda} S^{1/2} / (2e \times I_{\text{dark}})^{1/2}$ . The quality of the photodetector was further determined by fitting the relation of photocurrent and incident light power density with a power law,  $I_{\text{ph}} \approx P^{\theta}$ . As shown in Fig. 4d, the exponent  $\theta$  was fitted to be  $\approx 0.93$ , suggesting the SnS<sub>2</sub> had very few defects or traps to photo-induced electron/hole pairs in the test power density range.<sup>30</sup> From response and recovery curves in air (Fig. 4e and f), the rise time of the photodetector was  $\approx 7$  ms, while the decay time was  $\approx 6$  ms. The performance of our photodetector was more inspiring than the most reported SnS<sub>2</sub> based photodetectors shown in Table 1. Such superior responsivity and fast response rates were mainly due to the high-quality crystalline SnS<sub>2</sub> structure, large specific surface area, and surface trap states. For example, (a) the high-quality crystalline structure without low density of defects confirmed by the PL spectra and TEM characterizations contributes to a rapid diffusion of charge carriers.<sup>31</sup> (b) As well known, large specific surface area due to the ultrathin 2D structure could lead to higher sensitivity and prolong lifetime of photoexcited carriers because of a larger charge separation compared to their bulk counterparts.<sup>32,33</sup> (c) Trap states at the surface may prolong the lifetime of photoexcited carriers. Finally, both high responsivity and fast response rates suggest that the surface trapping and recombination relative to the defects reach an equilibrium in the SnS<sub>2</sub> photodetector.<sup>29</sup>

## Conclusions

In summary, we have grown a large amount of high-quality SnS<sub>2</sub> nanosheets using SnCl<sub>2</sub> as the precursors *via* a CVD method. The as-grown SnS<sub>2</sub> nanosheets have been verified by XRD, SEM,

Raman/PL, AFM, TEM, and photodetectors, respectively. The SnS<sub>2</sub> nanosheet has an indirect bandgap ( $\approx 2.2$  eV), and its thickness is 9 nm ( $\approx 15$  layers). The photodetector based on the SnS<sub>2</sub> nanosheets exhibits excellent performance, such as a high responsivity ( $1.4 \times 10^6$  mA W<sup>-1</sup>), a fast response rates (a response time of 7 ms and a recovery time of 6 ms), and a perfect external quantum efficiency (EQE) ( $2.6 \times 10^5\%$ ). This work may provide a new method to grow the SnS<sub>2</sub> nanosheets, which could help the research and application of future 2D semiconductor materials.

## Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

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